

Supporting Information

Water Formation Reaction under Interfacial Confinement: Al_{0.25}Si_{0.75}O₂ on O-Ru(0001)

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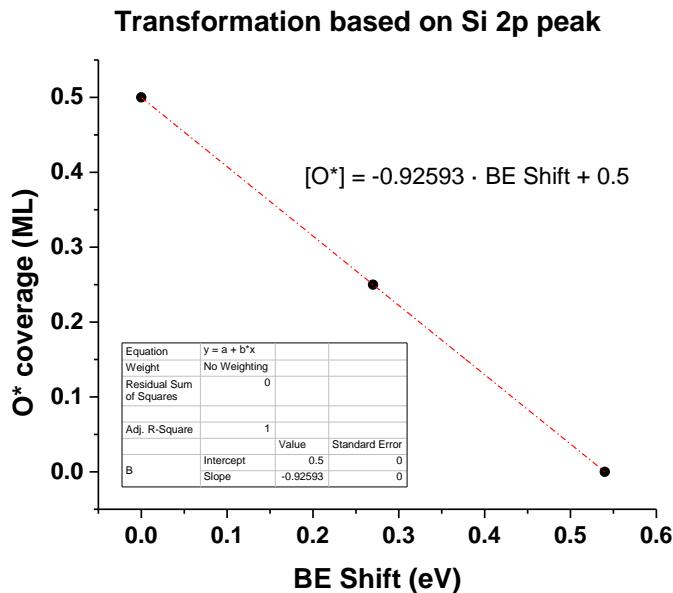


Figure S1. O* coverage vs BE shift of the Si 2p core level. This obtained relation was used to determine coverage in our experiments based on the measured BE shift.

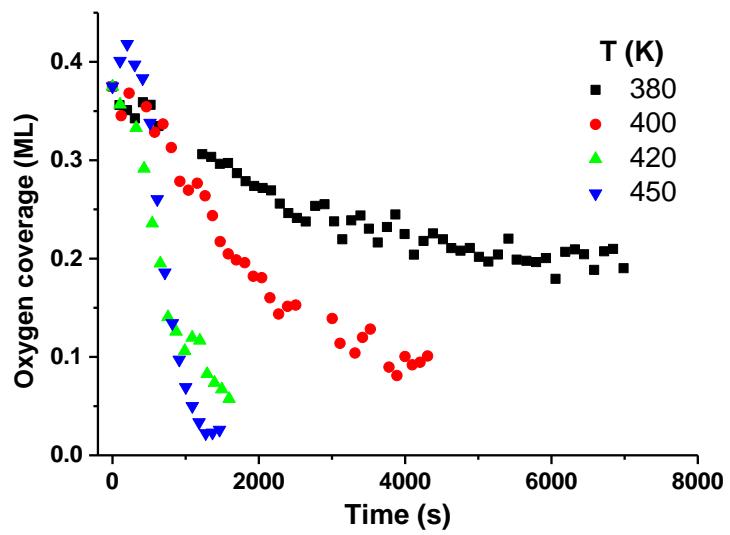


Figure S2. Temporal evolution of chemisorbed O-coverage at 380 K, 400 K, 420 K, and 450 K.